

## **Contributed Oral**

**O-1** Hidetaka Asoh (Kogakuin University)

Site-Selectivity of Anodic Film Formation by Bipolar Anodization

**O-2** Lina Sepulveda (University of Pardubice)

Wireless Anodization for the Preparation of TiO<sub>2</sub> Nanotube Layers

**O-3** Agnieszka Gabryelczyk (Guangdong Technion - Israel Institute of Technology)

Electrochemical impedance spectroscopy for characterization of TiO<sub>2</sub> thin layers: semiconducting and corrosion properties

**O-4** Mustaffa Ali Azhar Bin Taib (Pusat Latihan Teknologi Tinggi (ADTEC) Taiping)

The grassy structure of anodized TiO<sub>2</sub> nanotubes

**O-5** Jae H. Kim (Korea Institute of Materials Science)

Effect of the Morphology of Titanium Oxide Layers Formed by Anodizing on Electrical Conductivity and Corrosion Resistance in Strong Acidic Environments

**O-6** Sumin Lee (Pukyong National University)

Anti-icing Surface System of Ti-6Al-4V Alloy for Aircraft Using Anodization

**O-7** Peng Wang (Nagoya Institute of Technology)

Effects of Organic Additives on the Fabrication and Characteristics of Nanoporous TiO<sub>2</sub>-TiO-TiN films in Nitric-based Solution for LIB Anodes

**O-8** Syahriza Ismail (Universiti Teknikal Malaysia Melaka)

Synthesis of Crystalline ZrO<sub>2</sub> Nanotubes (ZNTs): Double Layer Formation Mechanism During Fluoride-Based Anodization

**O-9** Aleksandra Baron-Wiechec (Guangdong Technion - Israel Institute of Technology)

Porosity initiation mechanism in barrier-type alumina anodic film studied using <sup>18</sup>O tracer and Nuclear Reaction Analysis

**O-10** David Quintero (Hokkaido University)

Microstructure evolution of high-purity aluminum under different heat treatment temperatures and its influence on crystalline anodic layer formation for solid polymer capacitor applications

**O-11** Yuxin Jing (University of Yamanashi)

High Performance Aluminum Solid Electrolytic Capacitors using Self-doped Poly(3,4-ethylenedioxythiophene)

**O-12** Artur Rudowicz (Warszawski Instytut Technologiczny)

Green Anodizing of AA2024 with Organic Acids: Correlation Between Anodic Layers and Sol-Gel Coatings

**O-13** Masatoshi Sakairi (Hokkaido University)

Area-selective formation of porous alumina with solution flow type micro-droplet cell

**O-14** Adane Ayalew (Hokkaido University)

Efficient fabrication of through-hole porous anodic alumina membrane by 3D printed SF-MDC

**O-15** Takashi Yanagishita (Tokyo Metropolitan University)

Fabrication of Ordered Nanohole Arrays by Two-Step Anodization of Stainless-Steel Substrates

**O-16** Mana Iwai (Hokkaido University)

A Perchloric Acid-Free Electrolyte for Electropolishing of Aluminum Substrate: Sodium Chloride and Glycol Solutions

**O-17** Malgorzata Norek (Military University of Technology)

Porous anodic alumina photonic crystals: controlling photonic properties across a broad spectral range

**O-18** Maria Arenas (Centro Nacional de Investigaciones Metalúrgicas)

Anodizing Aluminium alloys in F-solutions

**O-19** Junji Nunomura (UACJ corporation)

Quantitative evaluation of heat-induced cracks in anodic oxide film on aluminum using cathodic polarization curves

**O-20** Chika Tanaka (Okuno Chemical Industries)

Hard Anodizing Process of Aluminum with High Thermal Cracking Resistance

**O-21** Sachiko Ono (Kogakuin University)

Nanostructure Analysis of Anodic Film Formed on Aluminum after Nickel Salt Sealing

**O-22** Xiaopei Li (Fujian Normal University)

Multifunctional composite coating on Mg alloy based on anodized film

**O-23** Manuel Hofinger (Johannes Kepler University Linz)

On the corrosion influence of anodization in a Magnesium-Ytterbium thin-film library

**O-24** Erli Lin (Nagoya Institute of Technology)

Fabrication of Mg-Si-W-O Composite Oxide Films on Magnesium Alloys by Hybrid Anodization for Enhanced Corrosion Resistance

**O-25** Ana Conde (Centro Nacional de Investigaciones Metalúrgicas)

Antimicrobial surface treatments to prevent indirect transmissions

**O-26** Toshiaki Yasui (Toyohashi University of Technology)

Plasma Electrolytic Oxidation of Selected Area by Pulsed Laser Irradiation

**O-27** canceled

**O-28** Piotr Zabinski (AGH University of Krakow)

The role of oxide layer on catalytical performance new strategy for high entropy oxides application

**O-29** Katarzyna Skibinska (AGH University of Krakow)

Evolution of Properties of High-Entropy Oxides fabricated by anodization of High-Entropy Alloys

**O-30** Zainovia Lockman (Universiti Sains Malaysia)

Comparative Study and Assessment of Anodic Films on Ti, Ni, and TiNi Alloys for Photocatalytic Degradation of Dyes

**O-31** Dawid Kutyla (AGH University of Krakow)

Synthesis and Evaluation of Urea Electrooxidation Activity of Ni-Pt and Ni-Ir Porous Alloys Obtained by Molten Salts Electrodeposition

**O-32** Tomoya Nagao (Hokkaido University)

Investigation of Activity Factors in Fe-Co-Ni Alloy Electrode Catalysts for Alkaline Water Electrolysis Prepared by Anodizing

**O-33** Yoshiki Konno (Kyoto Municipal Institute of Industrial Technology and Culture)

Formation of Porous Anodic Films on Electroplated Fe-Ni and their Electrocatalytic Properties for Oxygen Evolution

**Poster**    **June 3 (Tue), 17:00~**

**P-1**      Kazuhiro Nagahara (Nippon Chemi-Con Corporation)

Development of a 450V High-Voltage Aluminum Polymer Capacitor

**P-2**      Takumi Ambe (Hokkaido University)

Effect of pore size and porosity of porous alumina on the breakdown voltage of conductive polymer solid capacitors

**P-3**      Sho Ishiwata (Kogakuin University)

Anodization of Aluminum in Sodium Borate Solution Containing Glycerol at 85°C

**P-4**      Junichi Wada (Sakamoto Yakuhin Kogyo)

Properties of Barrier Type Anodic Alumina Film Formed in Phosphate Solution with Polyglycerol Addition

**P-5**      Boman Wang (Tokyo Metropolitan University)

Fabrication of Ideally Ordered Anodic Porous Alumina with Large Interpore Distances

**P-6**      Hsuan-Lin Hsieh (Hokkaido University)

Fabrication of Porous Anodic Aluminum Oxide Films by Anodizing in Trisodium Phosphate Solution for Injection Molding Applications

**P-7**      Katarzyna Tomczyk (Military University of Technology)

Sulfuric citric anodizing as a chromates-free anodizing of aluminum alloys

**P-8**      Ryunosuke Satake (Kogakuin University)

Effect of Type and Concentration of Electrolyte on Film Formation Efficiency in Bipolar Anodization of Aluminum

**P-9**      Mayuno Kuroiwa (Tokyo Metropolitan University)

Fabrication of Large Alumina Masks by Multistep Anodization and Application to the Formation of Metal Nanodot Arrays

**P-10**    Aika Hamada (Tokyo Metropolitan University)

Preparation of Alumina Membrane Filters with Framework Structures

**P-11**    Masahiro Kotani (HAMAMATSU PHOTONICS)

Application of through-hole porous alumina membrane for SALDI chips in mass spectrometry

**P-12** Takanori Matsubara (College of Industrial Technology)

Melanin-Based Black Dyeing of Anodized Aluminium with High Light Fastness

**P-13** Runyang Yu (Guangdong Technion-Israel Institute of Technology)

Electrochemical impedance spectroscopy for characterization of TiO<sub>2</sub> thin layers: semiconducting and corrosion properties

**P-14** Kyoichi Kohashi (Tokyo Metropolitan University)

Control of Pore Sealing in Anodic Porous Alumina by TiO<sub>2</sub> Thin Film Formation Using ALD

**P-15** Amon Kitayama (Kitami Institute of Technology)

Optimization of anodizing duration in pulsed anodization of NiTi alloys

**P-16** Mitsunobu Iwasaki (Kindai university)

Preparation of (Ba,Sr)(Zr,Ti)O<sub>3</sub> films by anodic oxidation of titanium under spark discharge conditions

**P-17** Yoichi Mori (Kurimoto)

Wear-resistant coatings formed by plasma electrolytic oxidation

**P-18** Fumiaki Ishigure (ULVAC)

Development of Micro Arc Oxidation treatment for vacuum equipment

**P-19** Juan Manuel Manuel (Universidad Autónoma de Nuevo León)

Study of the effect of substrate geometries on the characteristics of copper oxides obtained by anodizing

**P-20** Rajeena Uruniyengal (Military University of Technology)

Electrochemical oxidation of CuAg(3%) alloy in alkaline electrolyte

**P-21** Wojciech Aniol (Military University of Technology)

Electrochemical oxidation of brasses

**P-22** Kazuyuki Nishio (Tokyo University of Technology)

Formation of nanoporous anodic gold oxide films and spontaneous reduction to nanoporous gold

**P-23** Chien-Liang Lee (National Kaohsiung University of Science and Technology)

Anodic Intercalation Preparation of Defective Graphene Nanosheets for Supporting Pt nanocatalysts toward Glucose Oxidation Reactions

**P-24** Tatsuya Ohki (Haier Asia R&D)

The Study of Carbon-Nanotube Added Surface Treatment-CAST-

**P-25** Nozomi Hibino (Kogakuin University)

X-ray Fluorescence Analysis of Elements in Solution Using Drip Substrates Having Nanoporous Structure Formed by Anodic Etching and Anodization

**P-26** Kengo Kimura (Aichi Institute of Technology)

3D micron- to millimeter-sized structure fabrication of single crystal Si by etching in extremely alkaline concentration solution containing graphite

**P-27** Riku Tanaka (University of Hyogo)

Metal-Assisted Etching of Highly Doped p-Type Silicon Using Platinum Particles: Effect of Hydrofluoric Acid Concentration in Etching Solution

**P-28** Takuma Nakayama (University of Hyogo)

Metal-Assisted Etching of p-Si Using Thin Film Patterns of Pt, Ag, and Pt/Ag Double Layer